

Directed Self-assembly of Block Copolymers for Nano-manufacturing

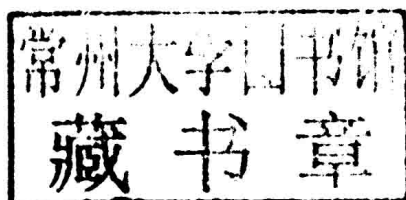
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Directed Self-assembly of Block Copolymers for Nano-manufacturing

Edited by

Roel Gronheid and Paul Nealey



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Part One

Physics and chemistry of block copolymer (BCP) materials

